



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

2813
#3/Election
5/19/00
Tia

Applicant(s): Hsiao, Tommy C.; Hui, Angela T.; Ogle, Robert B.; Pham, Tuan Duc;
Plat, Marina V.; Ramsbey, Mark T.; Shen, Lewis
Assignee: Advanced Micro Devices, Inc.
Title: Polished Flash Process With Metal Gates And Improved Planarity
Serial No.: 09/430,366 Filing Date: 10/28/99
Examiner: J. Chen Group Art Unit: 2813
Docket No.: M-7523 US

San Jose, California
May 12, 2000

BOX
ASSISTANT COMMISSIONER FOR PATENTS
Washington, D. C. 20231

RESPONSE TO RESTRICTION REQUIREMENT

Dear Sir:

In response to the Restriction Requirement of April 12, 2000, Applicants hereby elect without traverse Group I (i.e., Claims 1-15) for further prosecution in the above-referenced patent application. Applicants reserve the right to file one or more divisional patent application upon the unelected claims (i.e., Claims 16-20). If the Examiner has any questions regarding the above, the Examiner is requested to telephone the undersigned Attorney for Applicants at 408-453-9200.

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on May 12, 2000.

[Signature] 5/14/2000
Attorney for Applicant(s) Date of Signature

Respectfully submitted,

[Signature]
Edward C. Kwok
Attorney for Applicant(s)
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